

Solutions to Exercise: Photon Absorption

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Constants and input values. Units for length are μm !

In[48]:= $q = 1.6 \times 10^{-19}; (* \text{ in Coulomb} *)$

$\epsilon_0 = 8.854 \times 10^{-18}; (* \text{ F}/\mu\text{m} *)$

$\epsilon_{Si} = 11.9;$

$\mu = 1400 \times 10^8;$

(* for electronics, $\mu\text{m}^2/\text{Vs}$ *)

$UT = 0.0259; (* \text{ thermal voltage at room temperature, V} *)$

$n_i = 1.45 \times 10^{10} / 10^{12};$

In[54]:= \$Assumptions = $\lambda > 0;$

In[55]:= $LDEF = 6.3 \times 10^3 / 10^4;$

(* Absorption coefficient, converted from cm^{-1} to μm^{-1} *)

In[56]:= $\rho_0 = 1000 \times 10^4 (* \text{ Bulk resistivity } 1\text{k}\Omega\text{-cm, in Ohm}\cdot\mu\text{m} *);$

1. Light Loss

Write down expression for Absorption as a function of depth x

$$NP[x_, \lambda_] = \lambda \text{Exp}[-\lambda x];$$

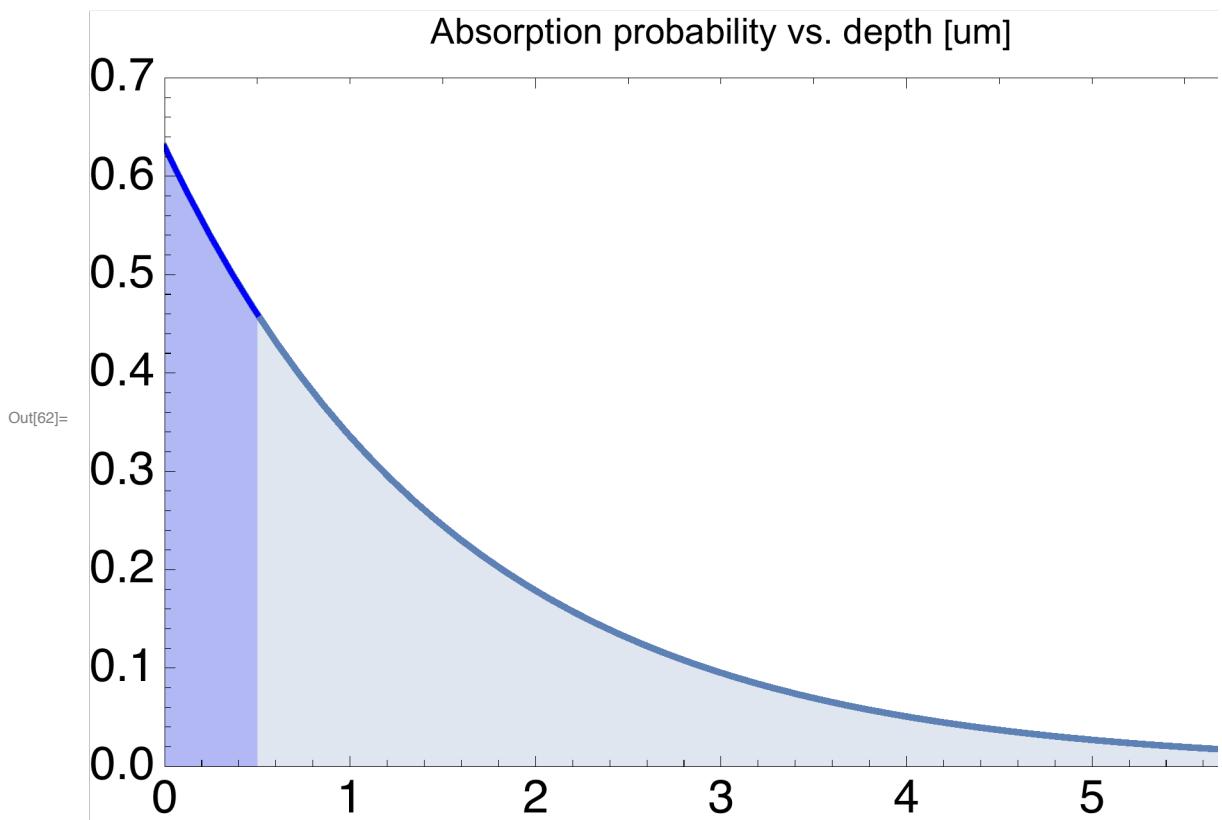
(* Number of photons absorbed
from depth x to x+dx is NP[x] dx *)

$$\int_0^\infty NP[x, \lambda] dx = 1$$

(* Check normalization *)

Out[58]= True

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In[62]:= Plot[
  {NP[x, LDEF], Which[ x < 0.5, NP[x, LDEF]]},
  {x, 0, 6}, PlotRange → {0, 0.7},
  Frame → True, Filling → Axis,
  ImageSize → Medium, PlotLabel →
  "Absorption probability vs. depth [um]"]
```



In[63]:= $\text{Absorption}[T1_, T2_, \lambda_] = \int_{T1}^{T2} NP[x, \lambda]$
 $\text{dx} (* \text{Absorption between } T1 \text{ to } T2 *)$

Out[63]= $e^{-T1 \lambda} - e^{-T2 \lambda}$

In[64]:= $\text{Absorption}[0, \infty, \lambda] // \text{Simplify}$

Out[64]= 1

```
In[65]:= DeadLoss = Absorption[0, 0.5, LDEF]
(* loss in dead layer *)
Out[65]= 0.270211
```

2. Voltage to get $\alpha = 90\%$ of remaining photons (between T1 and TX)

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In[66]:= Absorption[T1, TX, λ] == α * (1 - Absorption[0, T1, λ])
Out[66]= e^-T1 λ - e^-TX λ == e^-T1 λ α
In[67]:= Solve[%, TX] // First
Out[67]= {TX → ConditionalExpression[ $\frac{2 \pm \pi C[1] + \text{Log}\left[-\frac{e^{T1 \lambda}}{-1+\alpha}\right]}{\lambda}$ , C[1] ∈ ℤ]}
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```
In[68]:= % /. C[1] → 0
Out[68]= {TX →  $\frac{\text{Log}\left[-\frac{e^{T1 \lambda}}{-1+\alpha}\right]}{\lambda}$ }
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In[69]:= ReqDepth = TX /. %

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Out[69]=  $\frac{\text{Log}\left[-\frac{e^{T1 \lambda}}{-1+\alpha}\right]}{\lambda}$ 
```

In[70]:= RequiredDepth =

```
ReqDepth /. {λ → LDEF, α → 0.9, T1 → 0.5}
(* calculate result for
values in exercise in um *)
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Out[70]= 4.1549

Calculate the required voltage to get depletion depth 'RequiredDepth'

$$\text{In[71]:= } \text{ND} = \frac{1}{q \rho_{\text{bulk}} \mu} \text{ (* calculate n-doping of the bulk from the resistivity *)}$$

$$\text{Out[71]= } \frac{4.46429 \times 10^7}{\rho_{\text{bulk}}}$$

$$\text{In[72]:= } \text{ND} * 10^{12} /.$$

$\rho_{\text{bulk}} \rightarrow \rho_0$ (* convert μm^{-3} to cm^{-3} to check that the value makes sense *)

$$\text{Out[72]= } 4.46429 \times 10^{12}$$

$$\text{In[73]:= } \text{TDep} = \text{Limit}[$$

$$\sqrt{\frac{2 \epsilon_0 \epsilon_{\text{Si}}}{q} \frac{\text{NA} + \text{ND}}{\text{NA ND}} V_{\text{Bi}}} \sqrt{1 + \frac{V_{\text{Dep}}}{V_{\text{Bi}}}}, \text{ NA} \rightarrow \infty]$$

(*Limit of large NA *)

$$\text{Out[73]= } 0.00543153 \sqrt{\frac{V_{\text{Bi}} + V_{\text{Dep}}}{V_{\text{Bi}}}} \sqrt{V_{\text{Bi}} \rho_{\text{bulk}}}$$

$$\text{In[74]:= } \text{TDep} = \text{Assuming}[V_{\text{Bi}} > 0, \text{Simplify}[\%]] /. V_{\text{Bi}} + V_{\text{Dep}} \rightarrow V_{\text{total}}$$

$$\text{Out[74]= } 0.00543153 \sqrt{V_{\text{total}}} \sqrt{\rho_{\text{bulk}}}$$

$$\text{In[75]:= } \text{Solve}[\text{RequiredDepth} == \text{TDep}, V_{\text{total}}] // \text{First}$$

$$\text{Out[75]= } \left\{ V_{\text{total}} \rightarrow \frac{585162.}{\rho_{\text{bulk}}} \right\}$$

$$\text{In[76]:= } V_{\text{total}} /. \% /. \rho_{\text{bulk}} \rightarrow \rho_0$$

$$\text{Out[76]= } 0.0585162$$

We see: The diode is already thick enough for no sup-

ply voltage for this low doping.

At higher doping, we need some voltage, which can be checked by changing ρ_0 to $100\rho_0$.